Electronic Supplementary Information

Diameter-optimized high-order waveguide nanorods for fluorescence enhancement applied in ultrasensitive bioassays

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Fluorescence enhancement properties of the NRs without the Au layer

ZnO NR arrays were fabricated using the same procedure and method, whist the ZnO seed layer was deposited directly onto the Si substrate without pre-depositing an Au layer. The obtained six types of ZnO-NRs arrays are named as '*Z1*', '*Z2*', '*Z3*', '*Z4*', '*Z5*', and '*Z6*', growing from the aperture arrays with the same size as the *AZ* samples. The resulting ZnO NRs in each array have approximately the same diameter, height, and lateral arrangement to those on the substrate with the Au layer. The fluorescent images and fluorescence-intensity distribution of this new series of samples treated by R6G solutions at various concentrations are presented in Fig. S6. In absence of the Au layer, although the FE of all NRs arrays was lower that of the *AZ* samples, the *Z3* arrays with an average *d* of ~230 nm still presented the best fluorescence detection at all the given R6G concentrations, which is in good agreement with the performance of its associated *AZ3*. FDTD simulations were also performed for this case (Fig. S7). Similar to the *AZ* results, the NR with *d* of 230 nm also presents the strongest simulated evanescent field and *E*_{Interface}, confirming that the *d*dependent high-order waveguide modes plays a key role in the FE properties of ZnO NRs.

Comparing the fluorescence intensity measured from the *AZ3* and *Z3* treated by R6G solutions at various concentrations (1 μ M, 1 nM, and 1 pM), the Au layer was confirmed to enhance the detected fluorescence signal effectively (Fig. 3a). For instance, the fluorescence intensity of *AZ3* treated by 1 pM R6G solution was even stronger than that of *Z3* treated by 1 nM R6G. As a result, a super low LOD of 0.1 fM for R6G probe detection was achieved from *AZ3* (Fig. 2a), which is two orders improved compared with the LOD of the corresponding NRs arrays without the Au layer (10 fM, Fig. S6a–b). Since the thicknesses of the ZnO seed layer and the remaining PMMA layer are much larger than the required metal-fluorophore coupling distance (usually < 20 nm),⁵¹ metal enhanced fluorescence effect does not influence the FE properties of *AZ* arrays. This is further confirmed by the nearly the same fluorescence lifetimes of the R6G on the ZnO NR in the presence/absence of the Au layer (Fig. S9). It is worthy of mention that, the Au-covered Si showed a much higher diffuse reflectance than the bare Si substrate for excitation with wavelength > 500 nm (Fig. S9). Therefore, the Au layer may promote FE properties of the NR arrays in two ways: (1) to reduce the absorption of the Si substrate upon both the excitation and the emission light; (2) to enhance waveguiding properties of the ZnO NRs by providing a reflecting mirror.⁵² As confirmed by the FDTD simulations (Fig. S7), the evanescent field of the NRs with the Au layer shows ~1 fold enhancement, indicating the significant contribution of the Au layer to the high FE performance.

To further evaluate the FE performance of the AZ NR arrays, FE properties of the AZ3 and Z3 samples together with the PMMA layer, the ZnO seed layer, and a glass substrate were compared (treated by 1 μ M R6G and measured under the same conditions). As seen in Fig. 3b, the detected fluorescence intensity of R6G on AZ3 was ~2 fold as that on Z3, ~20 fold as that on the ZnO seed layer and PMMA layer. Notably, AZ3 resulted in ~300 fold enhancement of the detected fluorescence intensity in comparison to the glass substrate, which is higher than all the reported results of the ZnO-based FE platform.^{53,54}



Fig. S1 X-ray diffraction pattern of ZnO seed layer grown on (a) Au layer-coated Si substrate and (b) bare Si substrate.



Fig. S2 The geometries and parameters of the aperture arrays in the PMMA layer



Fig. S3 Atomic force microscopy images of the circular holes formed in the PMMA layer with the target diameters of (a) ~100 nm, (b) ~150 nm, (c) ~200 nm, (d) ~250 nm, (e) ~300 nm, and (f) ~400 nm, respectively. The scale bars are 2 μ m.



Fig. S4 Diameter distribution of the ZnO nanorods spouted out from the six types of the holes. The average diameters are (a) \sim 150 nm, (b) \sim 180 nm, (c) \sim 230 nm, (d) \sim 270 nm, (e) \sim 320 nm, and (f) \sim 410 nm, respectively.

Ar	ray	Average diameter (nm)	Α (μm²)	/ (a.u.)	I/A (µm⁻²)
A	Z1	~150	~0.68	~400	~590
A	Z2	~180	~0.82	~500	~610
A	Z3	~230	~0.98	~2000	~2040
A	Z4	~270	~0.99	~1100	~1110
A	Z5	~320	~1.06	~1000	~940
A	Z6	~410	~1.42	~1100	~770

Table S1 The average diameter, estimated surface area of a single AZ NR (A), measured fluorescence intensity (*I*), and normalized intensity (*I*/A) of AZ1–AZ6 arrays, treated by 1 μ M R6G solution.



Fig. S5 The |E| distribution on an *x*-*y* plane of the *AZ* NRs with different *d*.

Table S2 The calculated average $E_{interface}$ values of the NRs with the same *d* of 230 nm but different NR heights of 1.5, 1.4, 1.3, 1.2, 1.1, and 1.0 μ m.

NR Height	1.5 μm	1.4 µm	1.3 μm	1.2 μm	1.1 µm	1.0 µm
Average E _{interface}	6.42	6.21	6.23	6.19	6.14	6.07



Fig S6. (a) Fluorescent images and (b) fluorescence-intensity distribution of the Si/ZnO NRs samples treated by R6G solutions with different concentrations.



Fig. S7 (a) Configuration and (b) |E| distribution on an *x*-*y* plane of the *Z* NRs with different *d*. (c) |E| along the *y*-axis and (d) the evanescent field at the ZnO/air interface $E_{interface}$ of the *Z* NRs with *d* of 150, 180, 230, 270, 320, and 410 nm.



Fig. S8 |E| along the *y*-axis of the *AZ* and *Z* NRs with *d* of 230 nm.



Fig. S9 Time-resolved fluorescence spectra of R6G on the ZnO NRs in the presence/absence of the Au layer.



Fig. S10 Diffuse reflectance of the Au layer and the Si substrate.



Fig. S11 FTIR spectra of the pristine ZnO NRs and the GPTS-modified ZnO NRs.



Fig. S12 Fluorescence intensity measured from the AZ1, AZ2, AZ3, AZ4, AZ5 and AZ6 arrays as a function of CEA concentration.



Fig. S13 Fluorescence intensity measured from the AZ4 arrays as a function of CEA concentration.



Fig. S14 |E| distribution on an *x*-*y* plane of the AZ NRs with surrounding medium of n = 1.4.

References

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